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(12) **United States Design Patent** (10) **Patent No.:** **US D827,808 S**  
**Xiao** (45) **Date of Patent:** **\*\* Sep. 4, 2018**

(54) **INTUBATE LARYNGEAL MASK**  
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(72) Inventor: **Jinfang Xiao**, Guangzhou (CN)  
(\*\*) Term: **15 Years**

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(52) **U.S. Cl.**  
USPC ..... **D24/110; D24/110.5; D24/110.1**  
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USPC ..... D24/110.1, 110.4, 110.6, 127, 129, 110,  
D24/110.5  
CPC ..... A61M 16/0409; A61M 16/04; A61M  
16/0447; A61M 16/0415; A61M 16/0488;  
A61M 16/0463; A61M 16/0434; A61M  
16/0411  
See application file for complete search history.

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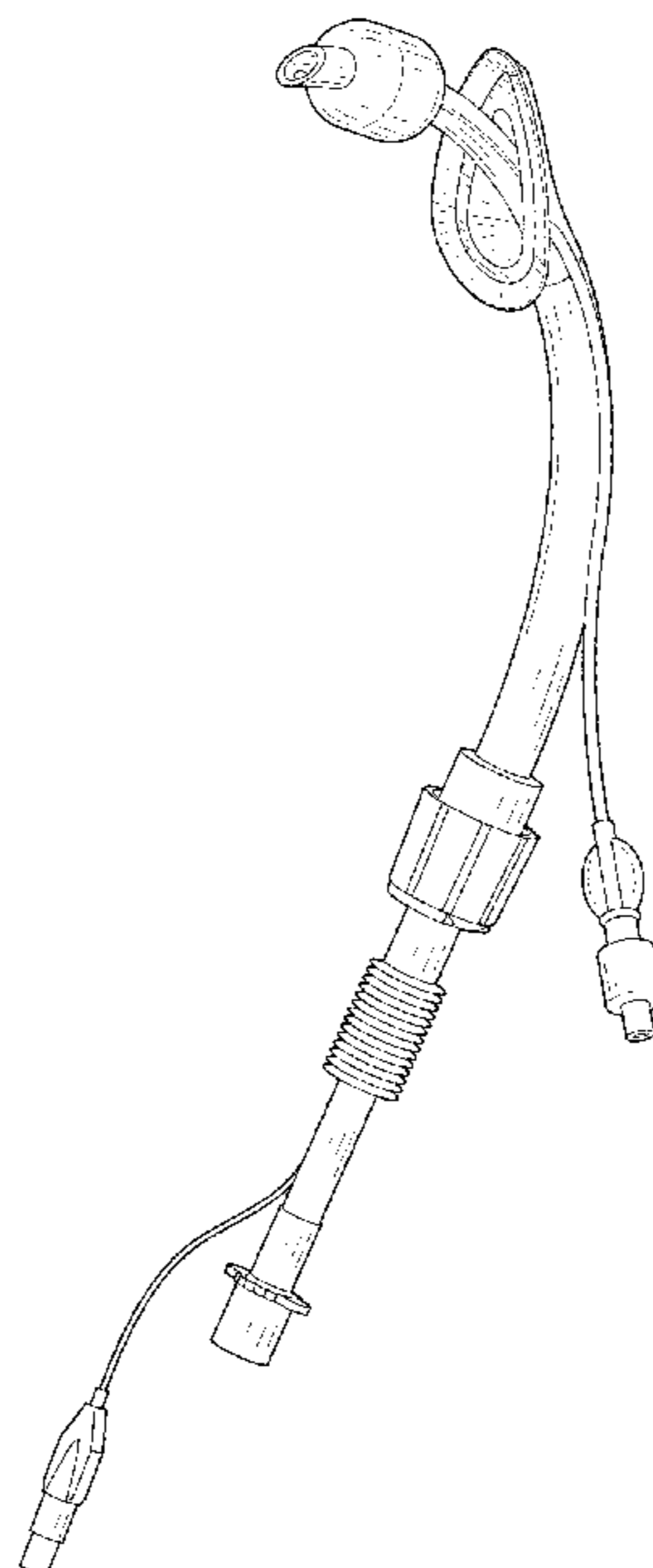
(57) **CLAIM**

The ornamental design for a intubate laryngeal mask, as shown and described.

**DESCRIPTION**

FIG. 1 is a perspective view of an intubate laryngeal mask showing my new design;  
FIG. 2 is a front elevational view thereof;  
FIG. 3 is a rear elevational view thereof;  
FIG. 4 is a left side elevational view thereof;  
FIG. 5 is a right side elevational view thereof;  
FIG. 6 is a top plan view thereof; and,  
FIG. 7 is a bottom plan view thereof.

**1 Claim, 6 Drawing Sheets**



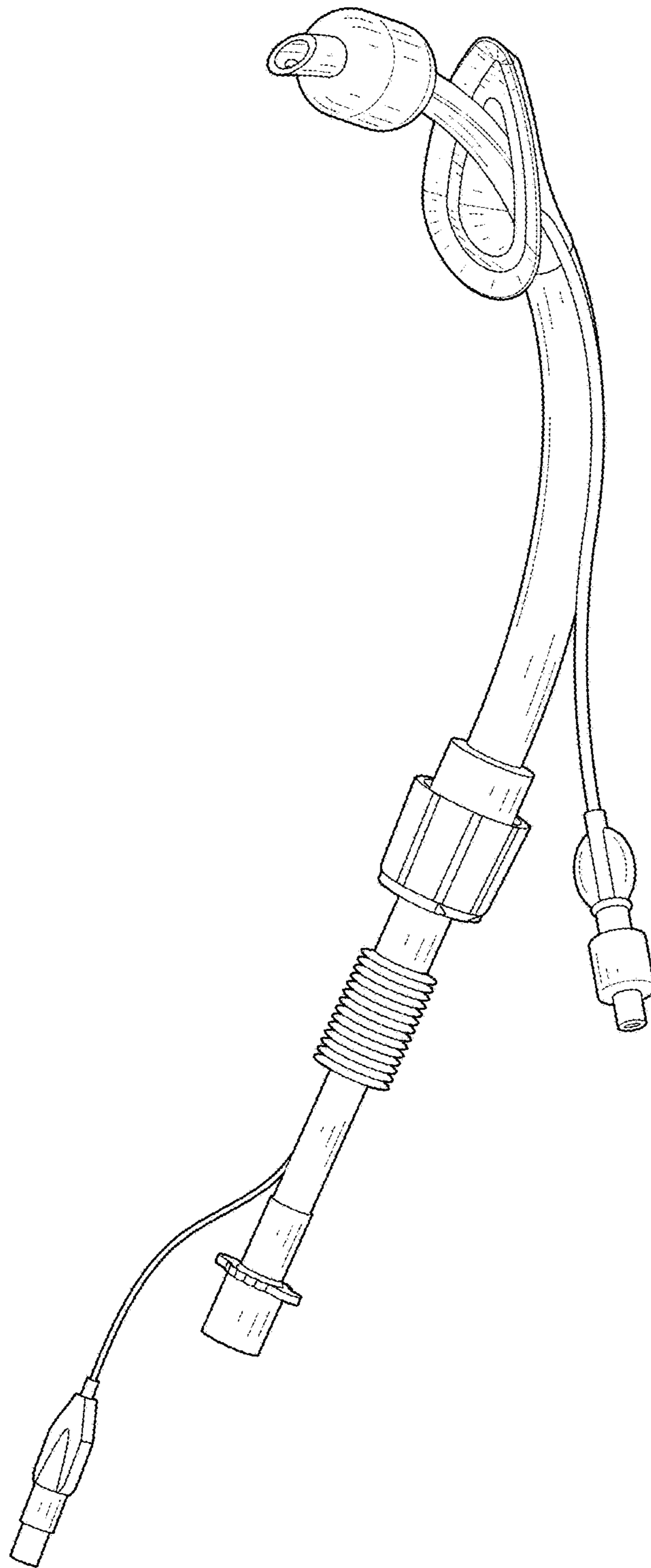


FIG. 1

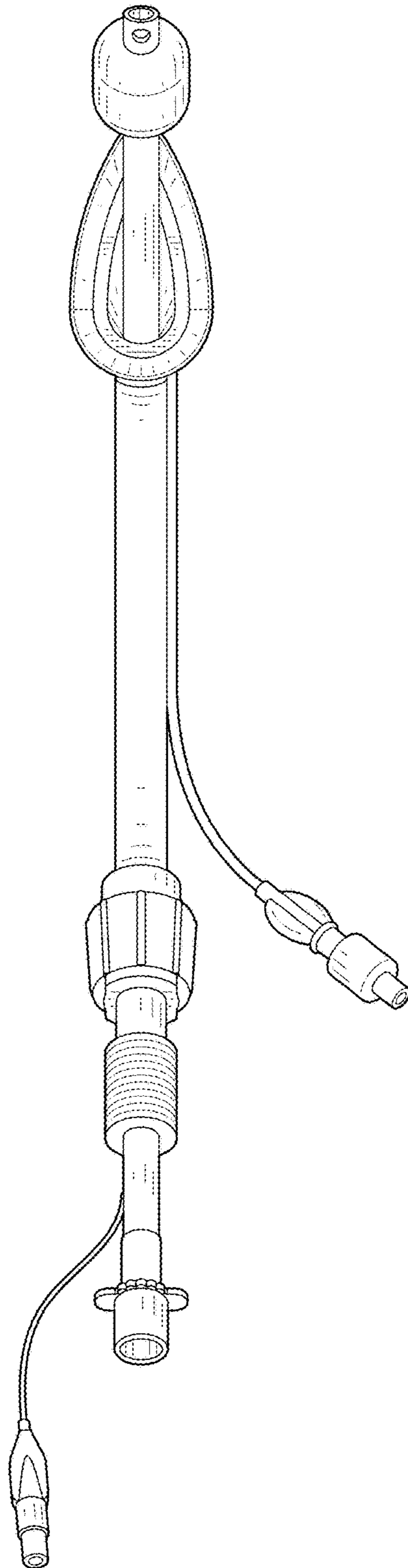


FIG. 2

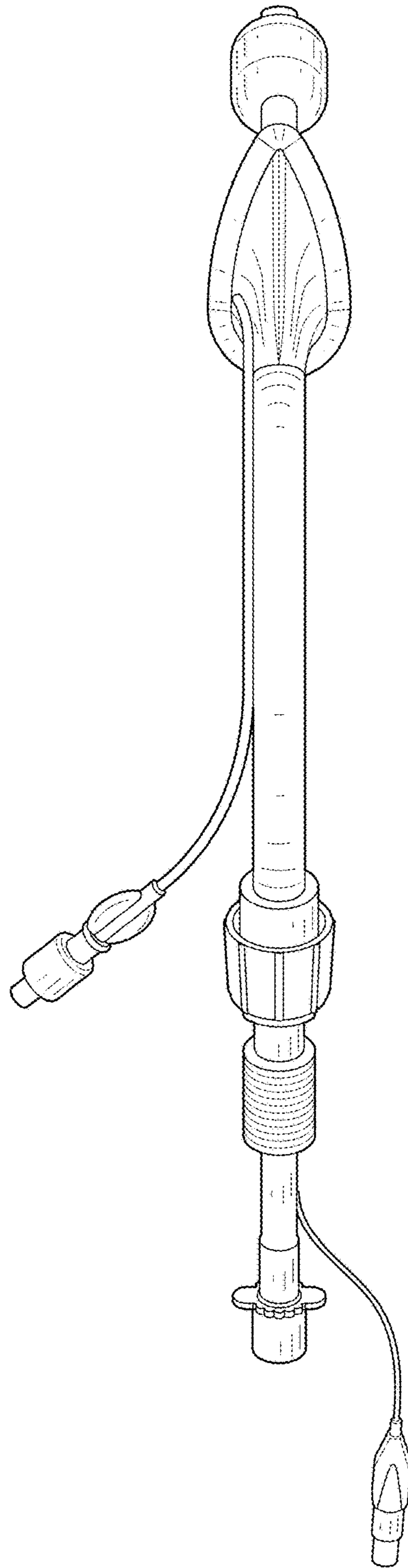


FIG. 3

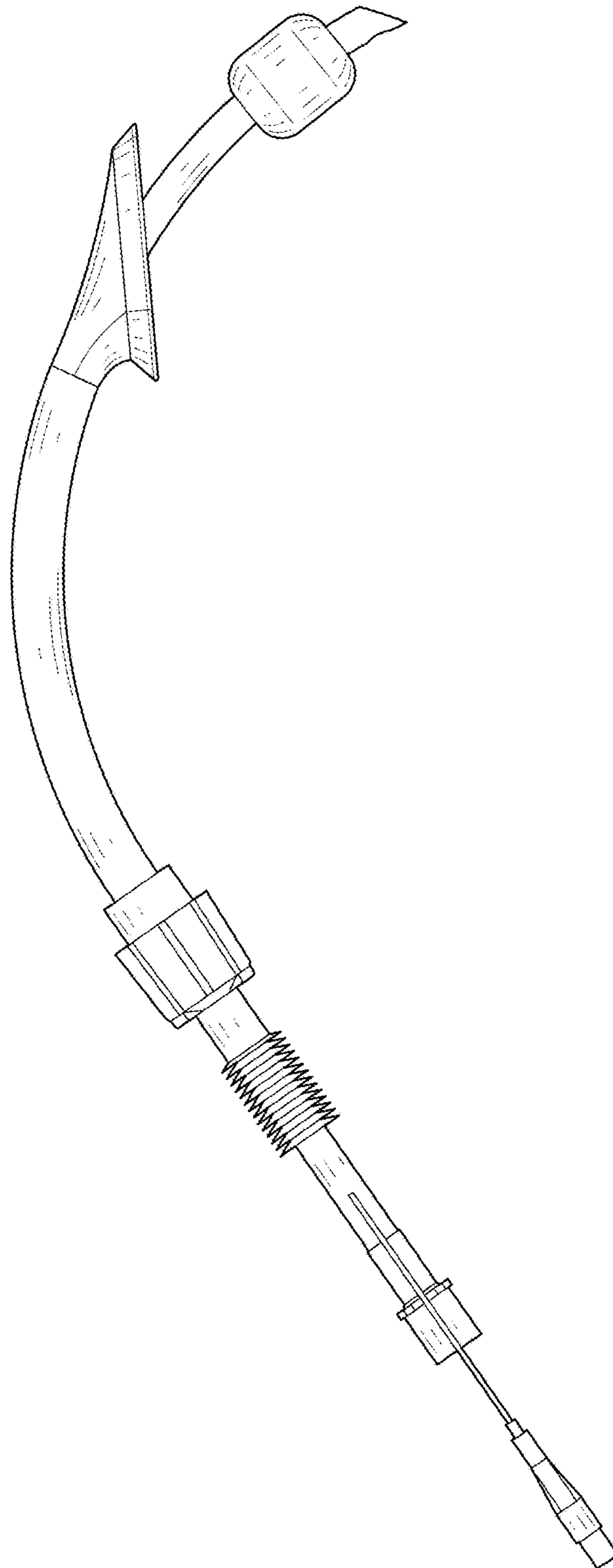


FIG. 4

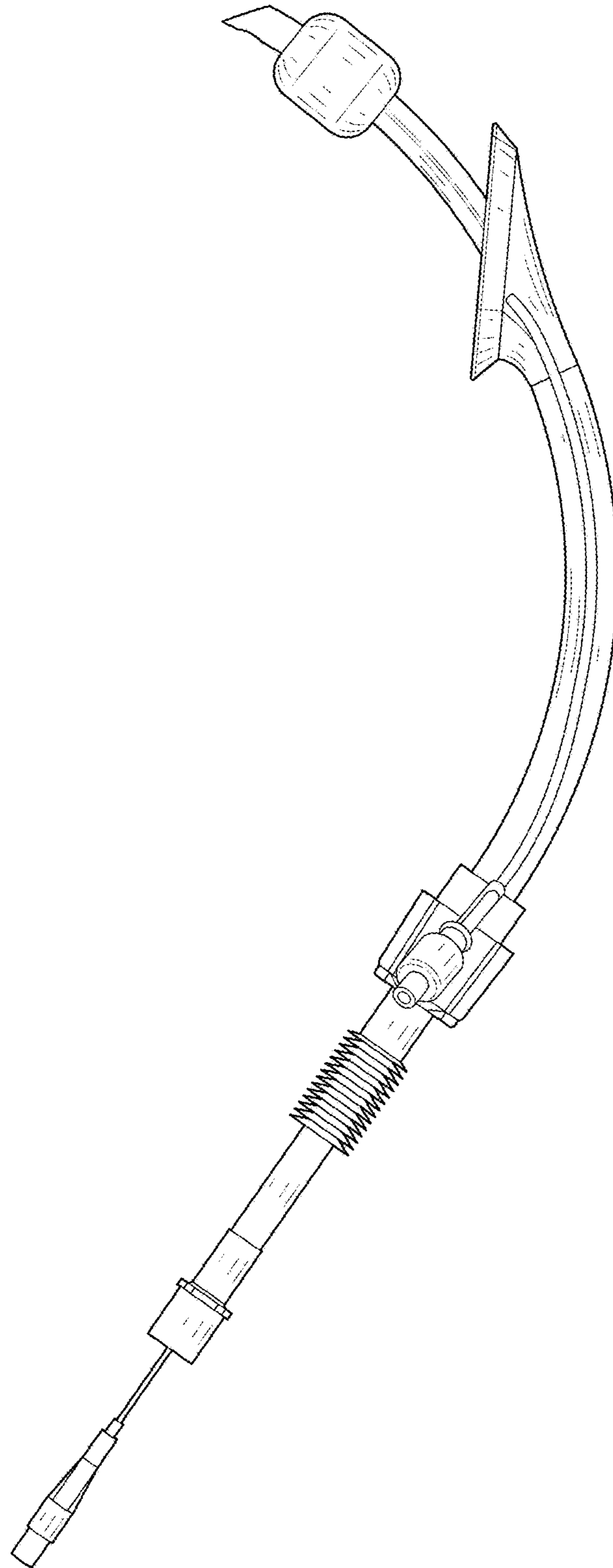


FIG. 5

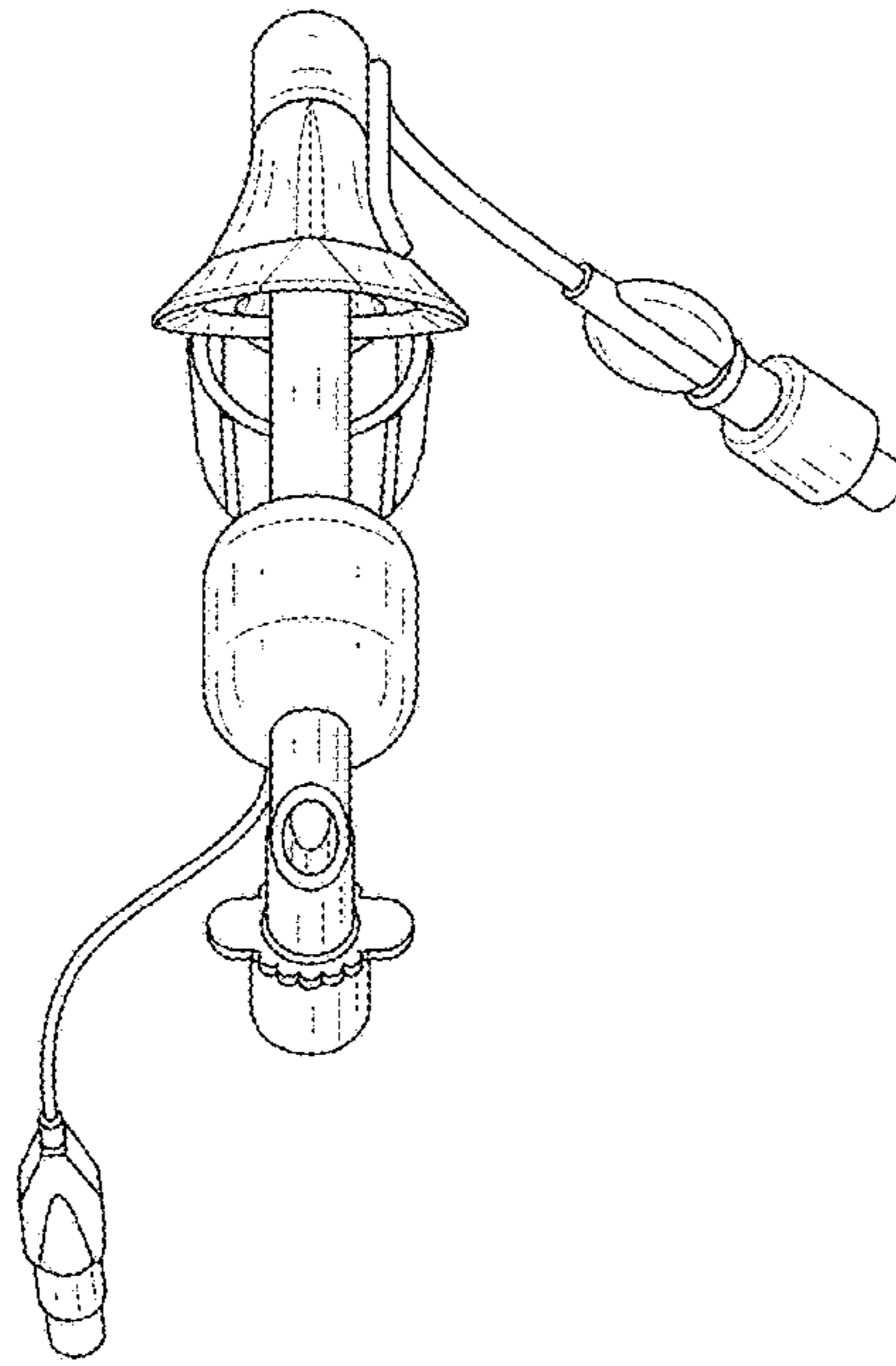


FIG. 6

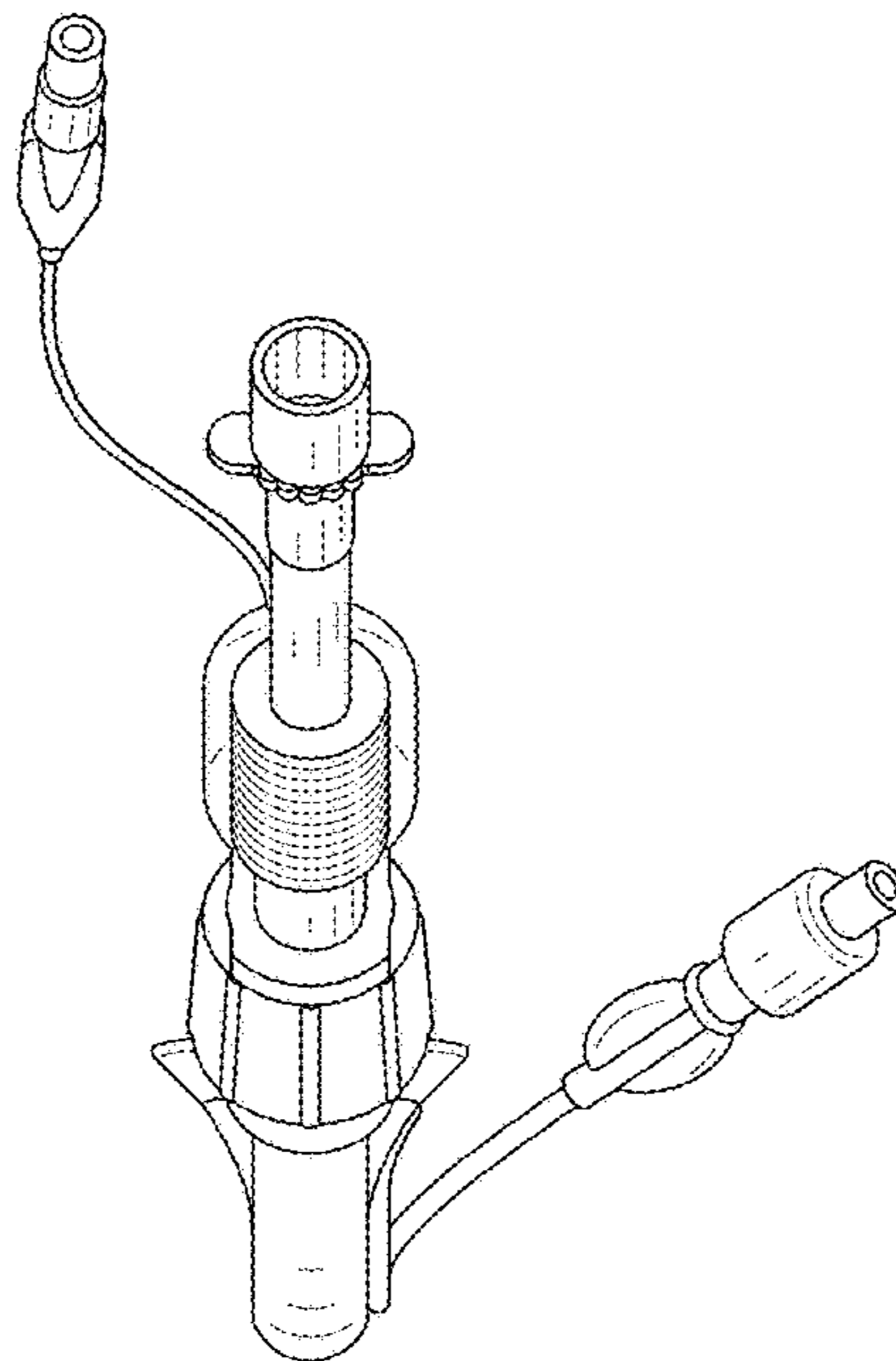


FIG. 7